

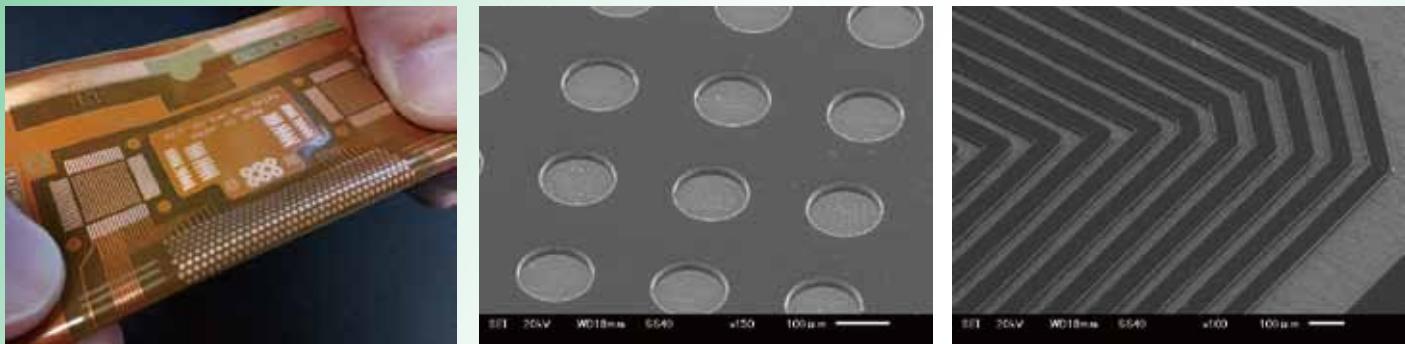


# 感光性カバーレイフィルム Photo Imageable Cover Lay Film

## 特徴 Features

開発品  
Developing

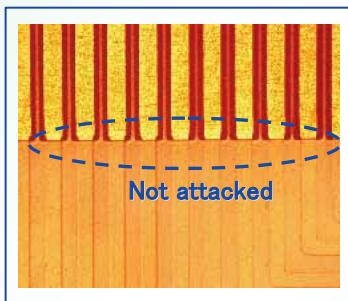
- 高解像性と高屈曲性の両立を実現した感光性ポリイミドフィルム  
Photo imageable polyimide film with coexistence of high resolution and high bendability
- 現行のプリント配線板製造ラインへの適用を実現  
Applicable to current PWB photolithography process
- 優れた耐熱性と絶縁信頼性と難燃性（VTM-0相当）を実現  
Excellent heat resistance, insulation reliability and flame resistance (VTM-0 equivalent)



## 特性 Properties

| Item                  | Condition  | Result         |
|-----------------------|--|----------------|
| Pencil hardness       | JIS 5400   | 4H             |
| Alkaline resistance   | 10wt%Na <sub>2</sub> CO <sub>3</sub> aq<br>25deg.C × 20min | Pass           |
| Heat resistance       | Solder floating 288deg.C × 10sec                           | Pass           |
| Au plating resistance | ENIG Ni:4um Au:0.1um                                       | Pass           |
| T <sub>g</sub>        | TMA  | 210deg.C       |
| Bendability           | 180deg. folding  | above 25 times |

### ★ENIG resistance 【Ni:4.0um Au:0.1um】



### ★Solder heat resistance

【288deg.C × 10sec × 2 times】

